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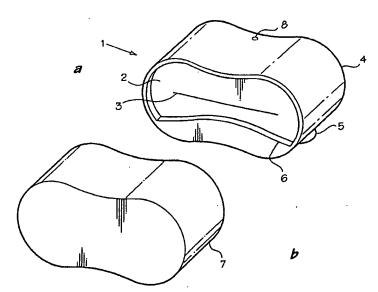
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(54) Title: NAIL POLISH REMOVER, ESPECIALLY FOR TOES



(57) Abstract: A nail polish removing device (1) particularly suited for removing nail polish from toenails, which has heretofore been relatively difficult or inconvenient, comprising a container (4) having a transverse opening (3) for receiving a toenail, a porous and pliable medium (2) disposed in the container (4) and adapted for scrubbing a toenail, a solution compartment located in a lower portion of the container (1), the solution compartment being capable of holding nail polish removing solution and facilitating contact of nail polish removal solution with the porous and pliable medium (2) to wet the medium (2) to facilitate nail polish removal. The (1) device may include suction cups (5) or other means for attachment to a floor or other surface.

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before the expiration of the time limit for amending the claims and to be republished in the event of receipt of cunendments

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